

DAILY SCHEDULE-OF-EVENTS

SUNDAY

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| Registration | 5:00 pm - 9:00 pm | Resort Tower, Ground Level, Registration Area |
| Welcome Reception | 7:00 pm - 9:00 pm | Resort Tower, Ground Level, Gold Room |
| Exhibit | 7:00 pm - 9:00 pm | Resort Tower, Ground Level, Gold Room |

MONDAY

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|---|---------------------|---|
| Registration | 8:00 am - 5:30 pm | Resort Tower, Ground Level, Registration Area |
| 1A: Plenary Session I | 8:15 am - 10:00 am | Resort Tower, Ground Level, Silver Room |
| Break | 10:00 am - 10:30 am | Resort Tower, Ground Level, Gold Room |
| 1B-1: Visible LED | 10:30 am - 12:30 pm | Resort Tower, Ground Level, Bronze Room 1 |
| 1B-2: Heterogeneous Integration/Wafer Bonding | 10:30 am - 12:20 pm | Resort Tower, Ground Level, Bronze Room 2 |
| Exhibit | 10:00 am - 4:00 pm | Resort Tower, Ground Level, Gold Room |
| Exhibit Reception/Lunch | 12:30 pm - 2:00 pm | Resort Tower, Ground Level, Gold Room |
| 1C-1: Doping in Nitrides | 2:00 pm - 3:20 pm | Resort Tower, Ground Level, Bronze Room 1 |
| 1C-2: Optical Device | 2:20 pm - 3:20 pm | Resort Tower, Ground Level, Bronze Room 2 |
| Break | 3:30 pm - 4:00 pm | Resort Tower, Ground Level, Gold Room |
| 1D-1: Nanostructure Epitaxy | 4:00 pm - 5:20 pm | Resort Tower, Ground Level, Bronze Room 1 |
| 1D-2: Nitride Power Device/HEMT | 4:00 pm - 5:10 pm | Resort Tower, Ground Level, Bronze Room 2 |
| LayTech Special Session | 6:00 pm - 9:00 pm | Resort Tower, 26th Floor, Skyview 5/6 |

TUESDAY

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|---|---------------------|---|
| Registration | 8:00 am - 8:00 pm | Resort Tower, Ground Level, Registration Area |
| 2A: Plenary Session II | 8:15 am - 10:00 am | Resort Tower, Ground Level, Silver Room |
| Break | 10:00 am - 10:30 am | Resort Tower, Ground Level, Gold Room |
| Exhibit | 10:00 am - 1:00 pm | Resort Tower, Ground Level, Gold Room |
| 2B-1: Heteroepitaxy of Mismatched III/Vs on Si | 10:30 am - 12:20 pm | Resort Tower, Ground Level, Bronze Room 1 |
| 2B-2: <i>In Situ</i> Monitoring/MOVPE Equipment | 10:30 am - 12:10 pm | Resort Tower, Ground Level, Bronze Room 2 |
| Lunch on Own | 12:30 pm - 2:00 pm | |
| Tuesday Poster Authors Set-up | 1:00 pm - 4:00 pm | Resort Tower, Ground Level, Gold Room |
| 2C-1: Etching/Passivation in Nitrides | 2:00 pm - 3:30 pm | Resort Tower, Ground Level, Bronze Room 1 |
| 2C-2: Nitride HEMT/N-Polar Growth | 2:00 pm - 3:40 pm | Resort Tower, Ground Level, Bronze Room 2 |
| Exhibit | 3:00 pm - 6:00 pm | Resort Tower, Ground Level, Gold Room |
| Break | 3:30 pm - 4:00 pm | Resort Tower, Ground Level, Gold Room |
| PS-1: Poster Session I | 4:00 pm - 6:00 pm | Resort Tower, Ground Level, Gold Room |
| Tech Next Lab Special Session | 6:00 pm - 6:30 pm | Resort Tower, Ground Level, Bronze Room 2 |
| Rump Session: When III-V Meets Silicon | 6:30 pm - 8:30 pm | Resort Tower, Ground Level, Silver Room |

WEDNESDAY

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|---|-----------------------|---|
| Registration | 8:00 am - 12:30 pm | Resort Tower, Ground Level, Registration Area |
| 3A-1: III/V Epitaxy for Devices | 8:20 am - 10:00 am | Resort Tower, Ground Level, Bronze Room 1 |
| 3A-2: hBN and Related Epitaxy | 8:20 am - 10:00 am | Resort Tower, Ground Level, Bronze Room 2 |
| Exhibit | 9:30 am - 12:00 pm | Resort Tower, Ground Level, Gold Room |
| Break | 10:00 am - 10:30 am | Resort Tower, Ground Level, Gold Room |
| 3B-1: Epitaxy for Photovoltaics | 10:30 am - 12:30 pm | Resort Tower, Ground Level, Bronze Room 1 |
| 3B-2: TMDC and Other Layered Materials and Characterization | 10:30 am - 12:30 pm | Resort Tower, Ground Level, Bronze Room 2 |
| Lunch on Own | 12:30 pm | |
| Excursions on Own | Beginning at 12:30 pm | |

THURSDAY

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|---|---------------------|---|
| Registration | 8:00 am - 6:00 pm | Resort Tower, Ground Level, Registration Area |
| 4A: Plenary Session III | 8:15 am - 10:00 am | Resort Tower, Ground Level, Silver Room |
| Break | 10:00 am - 10:30 am | Resort Tower, Ground Level, Gold Room |
| 4B-1: Epitaxy of As/P/Sb/Bi alloys for Devices | 10:30 am - 12:30 pm | Resort Tower, Ground Level, Bronze Room 1 |
| 4B-2: DUV LED | 10:30 am - 12:30 pm | Resort Tower, Ground Level, Bronze Room 2 |
| Lunch on Own | 12:30 pm - 2:00 pm | |
| Thursday Poster Authors Set-up | 1:00 pm - 4:00 pm | Resort Tower, Ground Level, Gold Room |
| 4C-1: Ga ₂ O ₃ Epitaxy and Characterization | 2:00 pm - 3:50 pm | Resort Tower, Ground Level, Bronze Room 1 |
| 4C-2: Nitride LD | 2:00 pm - 3:30 pm | Resort Tower, Ground Level, Bronze Room 2 |
| Break | 3:30 pm - 4:00 pm | Resort Tower, Ground Level, Gold Room |
| PS-2: Poster Session II | 4:00 pm - 6:00 pm | Resort Tower, Ground Level, Gold Room |
| Conference Banquet | 6:00 pm - 10:00 pm | Resort Tower, 26th Floor, Skyview 5/6 |

FRIDAY

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| Registration | 8:00 am - 1:00 pm | Resort Tower, Ground Level, Registration Area |
| 5A-1: In Containing Nitride | 9:00 am - 10:00 am | Resort Tower, Ground Level, Bronze Room 1 |
| 5A-2: Nanoscale Characterization | 9:00 am - 10:00 am | Resort Tower, Ground Level, Bronze Room 2 |
| 5A-3: IV-IV Materials and Devices | 9:00 am - 10:10 am | Resort Tower, Ground Level, Silver Room |
| Break | 10:00 am - 10:30 am | Resort Tower, Ground Level, Gold Room |
| 5B-1: Novel Nitride Material and Other Oxides | 10:30 am - 1:00 pm | Resort Tower, Ground Level, Bronze Room 1 |
| 5B-2: Fundamental Studies/Modelling of Epitaxy | 10:30 am - 12:50 pm | Resort Tower, Ground Level, Bronze Room 2 |
| 5B-3: Patterned Growth | 10:30 am - 12:50 pm | Resort Tower, Ground Level, Silver Room |